

IN THE UNITED STATES PATENT AND TRADEMARK OFFICE**D. Remarks**

Claims 1, 7-10, 12 and 17 have been amended.

Claim 1 has been amended to include "at least a portion of a reticle pattern extending through the non-resist deposited layer".

5 Claim 12 has been amended to include "at least a portion of a reticle pattern extending through the deposited layer".

Claim 17 has been amended to include "at least a portion of a reticle pattern extending through the reticle patterned layer".

10 The remaining amendments provide antecedent basis to terms added/modified in independent claims 1, 12 and 17.


It is believed that the amendments present no new matter.

Very particular examples of such features are set forth in Applicants' Specification and figures. As but two examples, FIG. 1A shows a reticle pattern extending through inspected layer
15 102-2, as described in Applicants' Specification at Page 7, Lines 6-9. Applicants' FIG. 2D shows a reticle pattern extending through layers 202-10 and 202-11, as described in Applicants' Specification at Page 10, Lines 14-22.

Of course, Applicants' claims should not be construed as being limited by such very particular embodiments.

20 The present claims 1-6, 8-19 and 22-24 are believed to be in allowable form. It is respectfully requested that the application be forwarded for allowance and issue.

Respectfully Submitted,

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